



ARRADIANCE®

Simulation of Timing Determinants: Predictions and Results

Neal Sullivan

Presented to: The Factors that Limit Time Resolution in
Photodetectors, Workshop 28-29 April 2011



Perspective

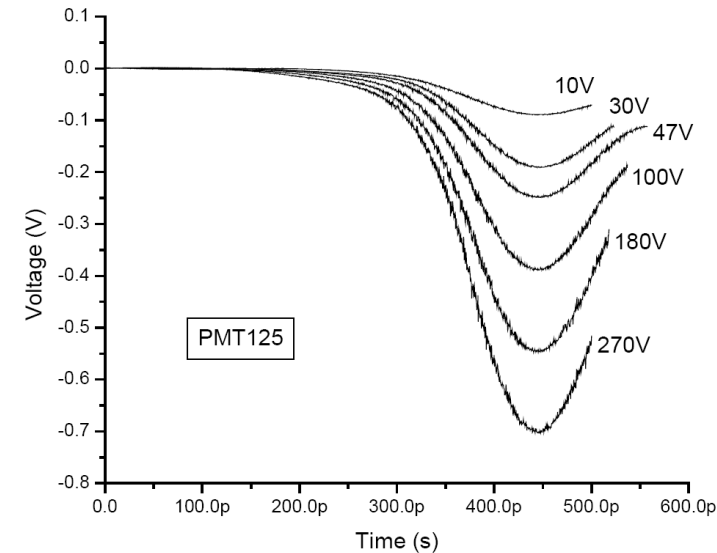
Remember that all models are wrong; the practical question is how wrong do they have to be to not be useful.

◀ Box & Draper, *Empirical Model-Building*, p. 74

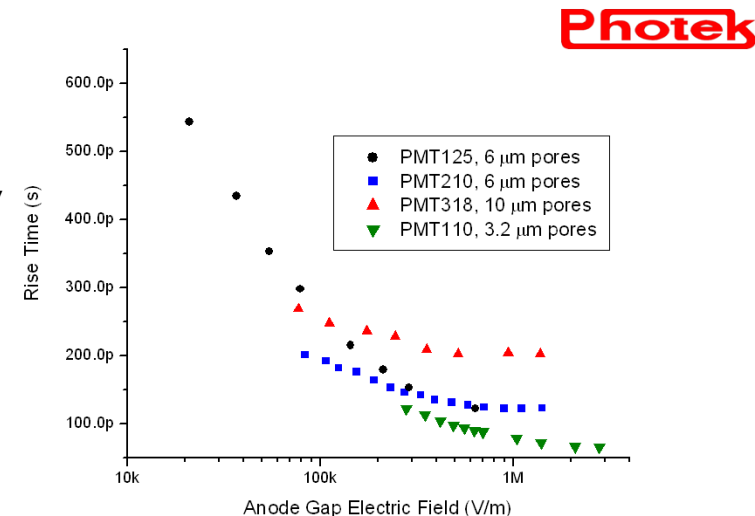
MCP-PMT timing (rise time) breakdown

J. Milnes and J. Howorth, "Picosecond time response characteristics of microchannel plate PMT detectors," Proc. SPIE 5580, 730 (2005); doi:10.1117/12.568180

- ◀ 1. Cathode Gap - Small effect
 - ◀ electrons emitted from cathode have a small energy ($< 2\text{eV}$) vs. the gap field ($> 200\text{eV}$).
- ◀ 2. MCP Stack
- ◀ 3. Anode Gap - Similar to cathode
 - ◀ except electrons leaving MCP have significant variation in lateral velocity



◀ "We have found that the rise time of MCP-based PMT detectors is principally governed by the variation in transit time through the MCP pores and the variation in exit velocity from the MCP stack."



MCP– Main source of rise time spread

J. Milnes & J. Howorth, "Picosecond time response characteristics of microchannel plate PMT detectors," Proc. SPIE 5580, 730 (2005); doi:10.1117/12.568180

S. Matsuura, S. Umebayashi, C. Okuyama, K. Oba, "CHARACTERISTICS OF THE NEWLY DEVELOPED MCP AND ITS ASSEMBLY," IEEE Trans. Nuc. Sci. Vol. NS-32, 1, February 1985

- ⚡ Primarily due to the many different possible path lengths (and hence transit times) of the electron avalanche through the MCP pores. Main factors:
 - ⚡ Pore size: Using narrow pore MCPs would be expected to reduce the path length variation.
 - ⚡ Bias angle: Uniformity of cascade initiation
 - ⚡ Number of MCPs in the stack produce wider variation of path length and is therefore expected to increase rise time.
- ⚡ The variation in transit time through the MCP pores is affected more by size and bias angle of the MCP pores rather than the number of MCPs.
- ⚡ The spread of the rise time caused by variations in the exit velocity from the MCP stack can be severely reduced by increasing the electric field from the MCP to the anode.

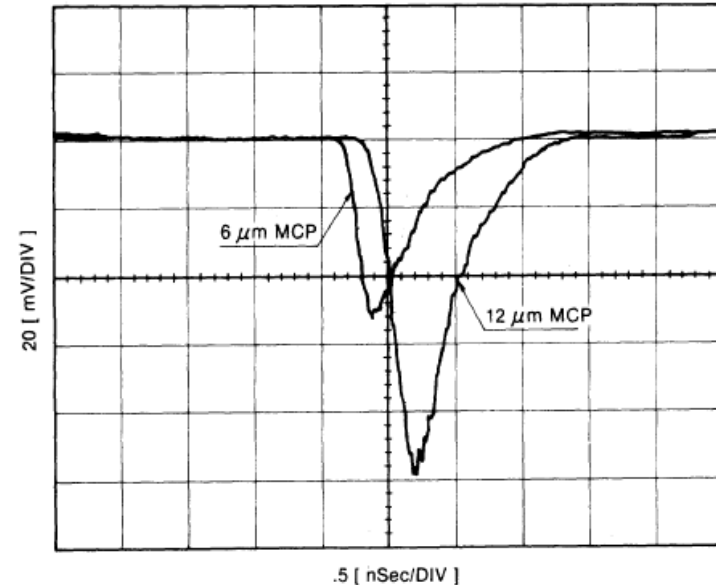


Fig. 13. Impulse responses of 2-stage 6 μ m MCP-PMT and 2-stage 12 μ m MCP-PMT

Table 1 Comparison of timing characteristics of 2-stage 6 μ m MCP-PMT and 2-stage 12 μ m MCP-PMT

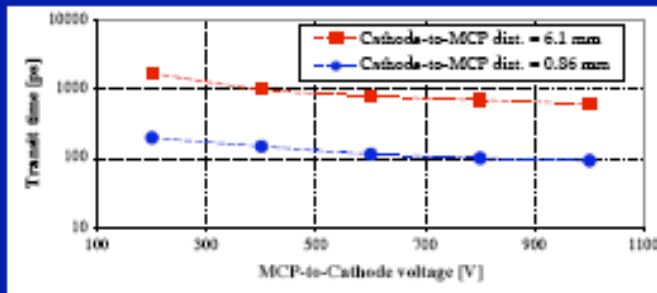
		6 μ m Channel	12 μ m Channel
RISE TIME	(nSec)	.167	.245
FALL TIME	(nSec)	.721	.716
TRANSIT TIME	(nSec)	.406	.650
TRANSIT TIME SPREAD	(nSec)	.067	.081

Experimental results: MCP-PMT

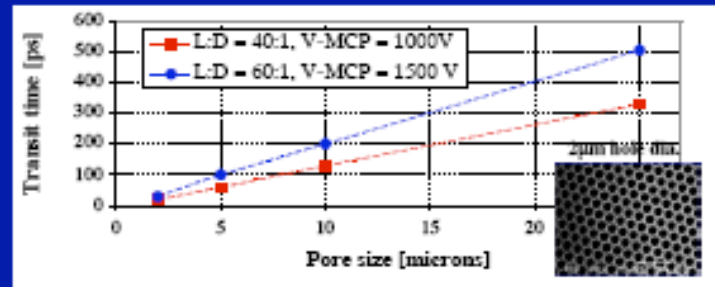
MCP-PMT: transit time & gain

Burle/Photonis information

Transit Time = $f(V_{\text{cath_to_MCP}})$:



Transit Time = $f(\text{Pore size})_{L:D}$:

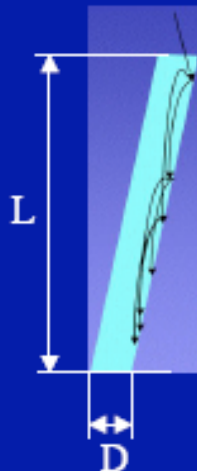


Transit time spread:

- Increased voltage or decreased gap can reduce the transit time.
- Smaller pore size smaller the transit time.

MCP Gain:

- Typical secondary yield is 2 per each strike of the wall.
- **L:D = 40:1** seems to be optimum design; for this ratio there are typically 10 strikes, i.e., Gain $\sim 2^{10} \sim 10^3$ per single MCP plate; $G \sim e^{(A \cdot L/D)}$
- For 10 μm dia. MCP hole, a ratio of 40:1 cannot be achieved for a 50x50 mm² size MCP (too fragile); therefore, a ratio of 60:1 is used. As a result, such MCP has slightly worse transit time.



2/25/07

J. Va'vra, MCP-PMT Detectors,
Photonis, Brive, France

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CASCADE First Order Gain (FOG) Analysis

1. Adams, J.; Manley, B. W., "The Mechanism of Channel Electron Multiplication," IEEE Trans. Nuc. Sci., v13, 3, p88

◀ e. g. Adams¹

$$G = \left(\frac{KV_o^2}{4V\alpha^2} \right) \frac{4V\alpha^2}{V_o}$$

◀ Before and After Emisive Coating - 60:1 LD, 12um Pitch, 12 Degree Bias

Change Model with Yellow Columns

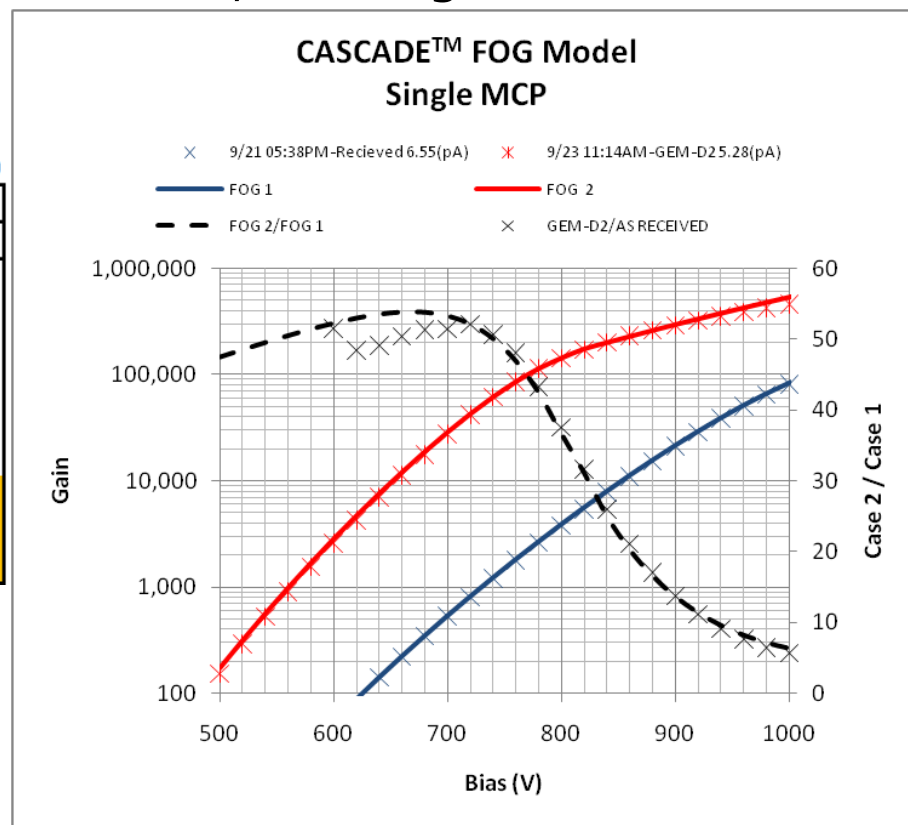
9/23/2009

Does not include tilt angle, Pore Dia, I/O Field, Charging effects

Changeable Parameters	FOG 1	FOG 2	FOG 2/FOG 1	Description
	0.6	0.6	1.00	Open Area Ratio
	5	7	1.40	SEY Constant (First Impact)
	0.5	0.5	1.00	End Spoiling in Diameters
	60	62	1.03	L/D Ratio
	1.04	1.35	1.30	SEY Constant (Relative to D2)
	12	12	1.00	Bias Angle (Degrees)
	120	100	0.83	MCP R (MΩ)
	6.55	5.28	0.81	Input I (pA)
	8.0%	8.0%	1.00	SAT Coefficient (% Strip)

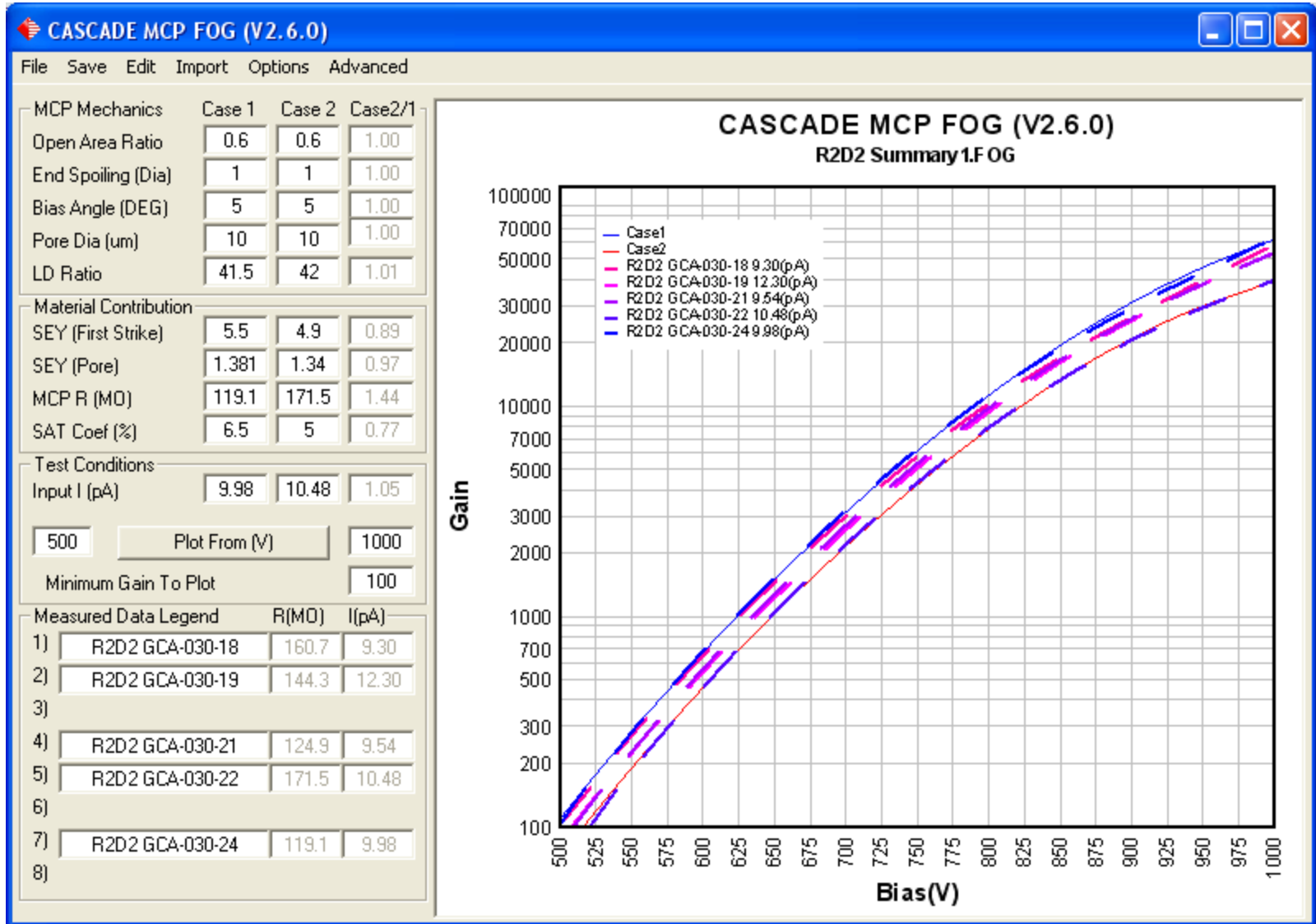
FOG Analysis Results For GEM-D2

1. 40% increase in first strike SEY
2. 30% increase in pore cascade SEY
3. 3% increase in apparent LD ratio



Solid line is modeled

CASCADE FOG 40:1 LD 10 um Pore MCP

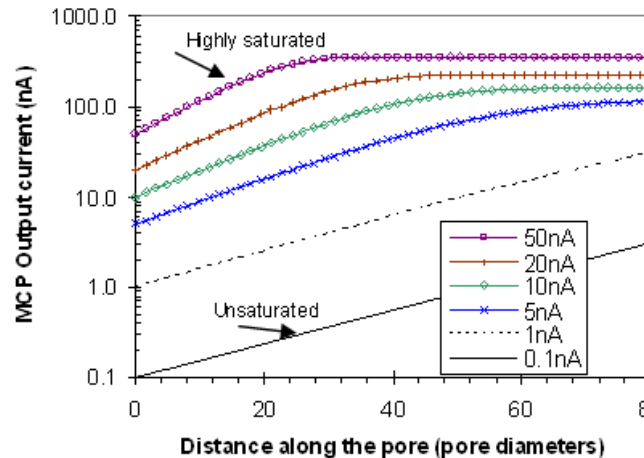
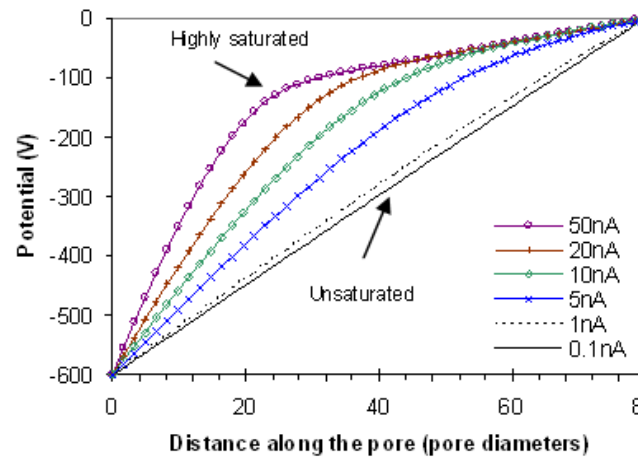
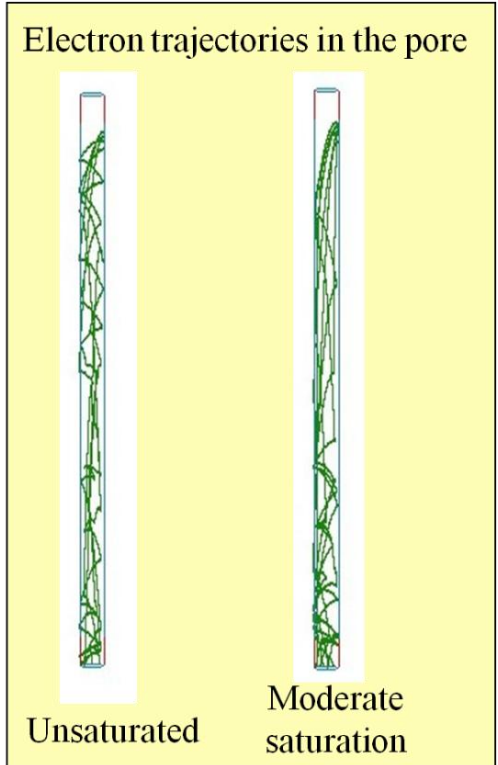
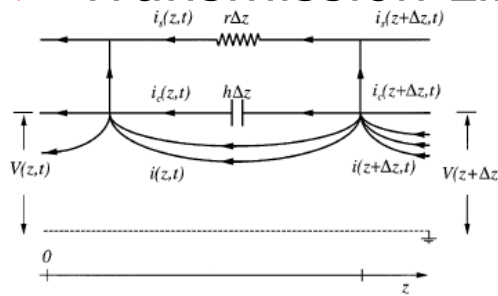


Models – (Tremis) Macro Giudicotti¹

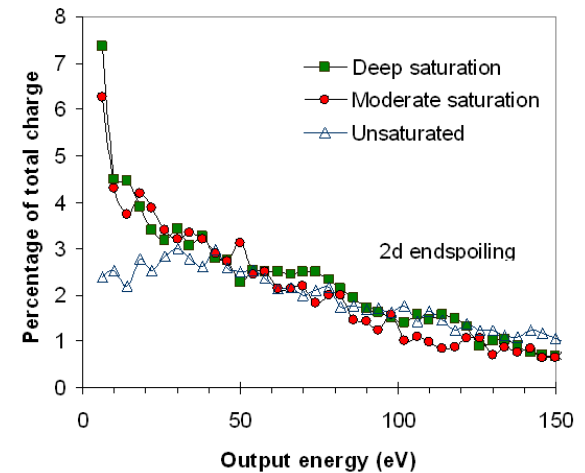
L. Giudicotti, Nucl. Instr. Meth. A 480 (2002) 670.

3D microscopic model with “super-electron”.

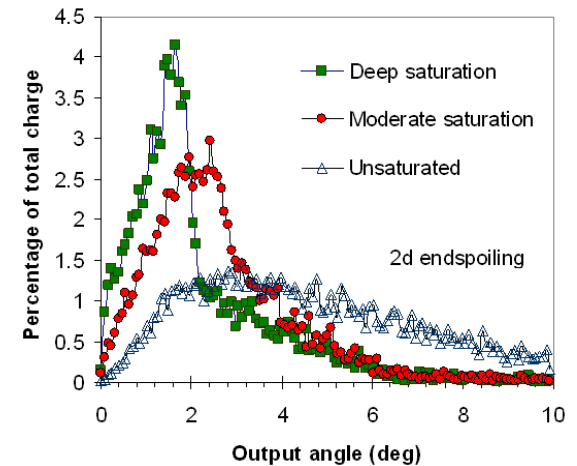
Transmission Line



Output energy distribution

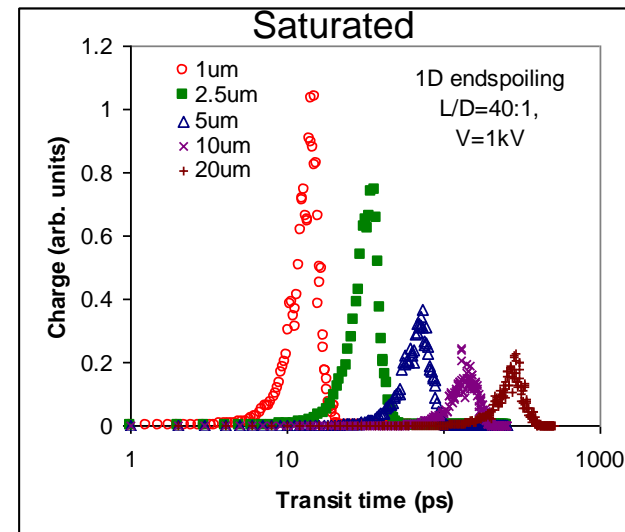
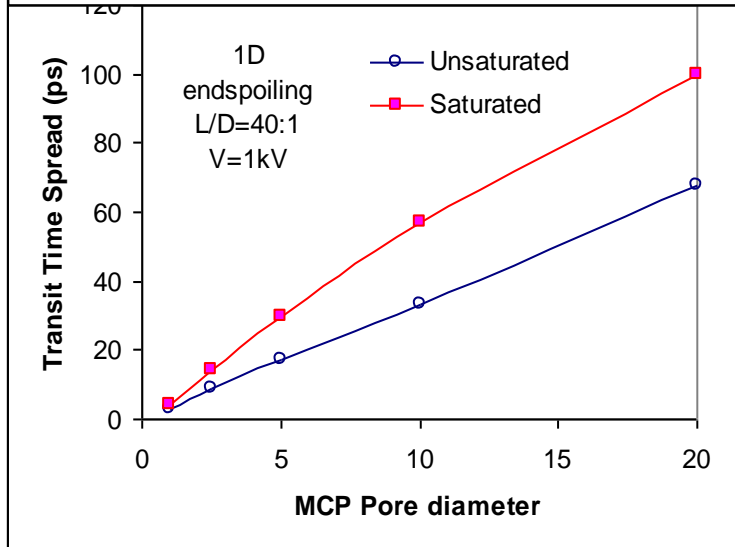
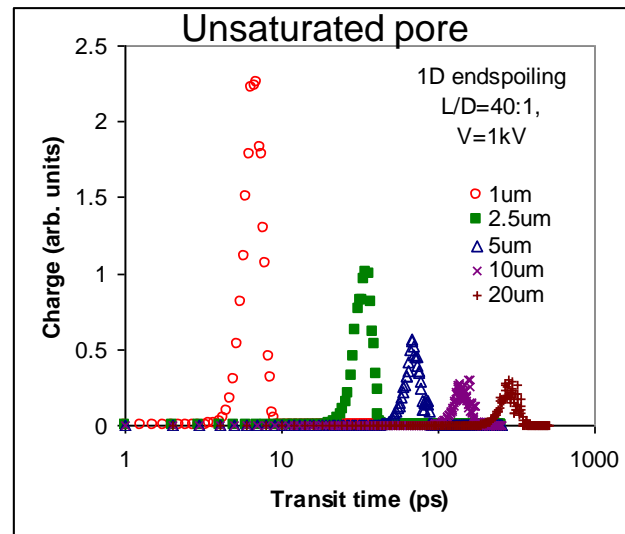
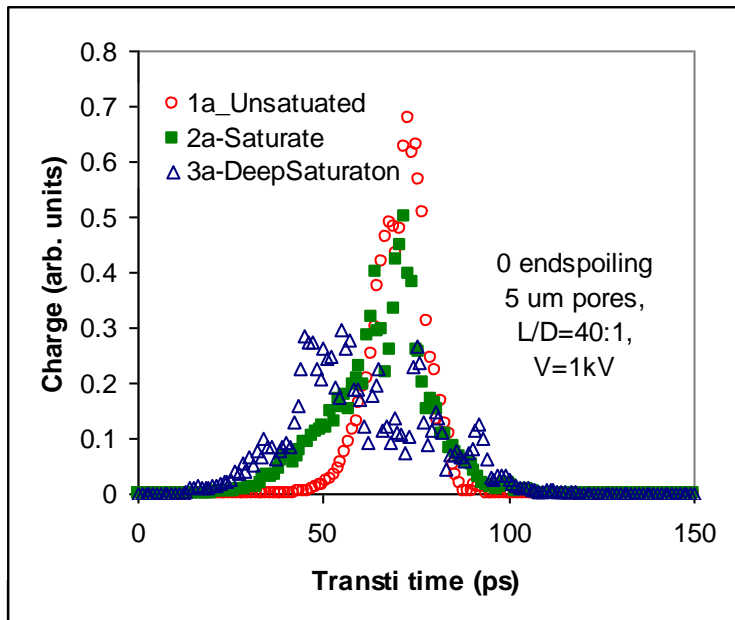


Output angular distribution





Macro-Micro Treatment TTS vs. pore diameter





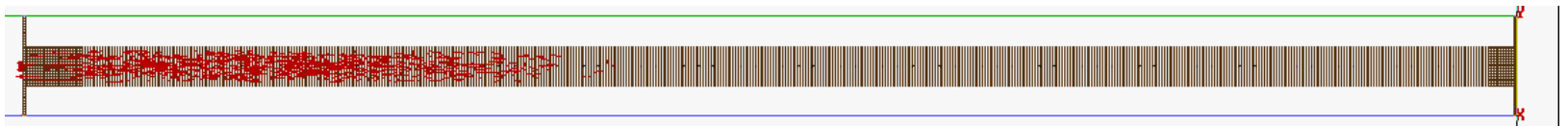
MCP CASCADE Simulation

About the model:

- ⚡ MCP Cascade model is a single electron event Monte Carlo simulation of a an MCP pore and extraction parameters
- ⚡ At a microscopic level, the model accounts for the following.
 - ⚡ 3D geometry and potential array for flight characteristics within, and outside the pore
 - ⚡ End spoiling (extraction) fields and penetration
 - ⚡ Material SE characteristics including yield and SE energy
 - ⚡ Cosine angular distribution of SE including normal vector correction of surface strikes based on geometry
 - ⚡ Real time (event based) beam potentials and effects on SE creation
 - ⚡ Real time (event based) wall charging potentials and effects on SE creation

The model predicts and reports:

- ⚡ Single event gain based on input geometry, materials, and MCP bias potentials and extraction potentials
- ⚡ Particle output statistics at the end of the pore, and remote anode including
 - ⚡ Energy distributions
 - ⚡ x' , y' , and r' angle distribution
 - ⚡ x , y , and z velocity distribution
 - ⚡ x , y , and z positions and distribution
 - ⚡ Time of flight distribution
 - ⚡ Tab delimited particle output files



Standard User Interface CASCADE™

CASCADE (4.1.4)

File Folders Options Utilities

Current CASCADE definition file and Data Output Path

Current File: C:\Users\DavidRBeaulieu\Desktop\CASCADE\CASCADE MODEL\MCP_EXAMPLE.def

Output Path: C:\Users\DavidRBeaulieu\Desktop\CASCADE\CASCADE OUTPUT

Build New Pore Potential Array

L/D Ratio: 50

Pore Bias (Deg): 5

ES In (D,tilt): 0.5 5

ES Out (D,tilt): 2 -5

PA Size (MB): 150.8

Skip PA Refine Build PA

System Settings

Pore Diameter (mm): 0.005

MCP Thickness (mm): 0.25

V1z - PC (mm): .250

V1 Delta (-V): 350

V2 MCP (+V): 700

V3z - AN(mm): .250

V3 Delta (+V): 700

View LUA View Fly View PA Copy

```

ARRADIANCE CASCADE V4.00 04/28/11 05:47:39
LD=50 L=250.0um D=5.0um B=5.0° ES1=0.5DX5.0° ESO=2.0DX-5.0°
PA(V) V1= -7 V2= 700 V3= 714
PA(V/mm) V1= 1400 V2= 2800 V3= 2800
Mat Pw R2D2 3.87 ES1 NiCr 1.85 ESO NiCr 1.85
SIM: #E/SIM 1 #E/E 1
    
```

Ev#	TOF	TOFac	Zac	#s	#C	KEas	°as	SEYa	BSYa	EYadt
1	1.0	0.5	0.0059	1	6	361.1	85.2	6.00	0.00	6.0
1	2.0	1.5	0.0074	2	6	195.0	79.9	3.50	0.00	1.0
1	3.0	12.1	0.0717	3	11	247.7	83.0	4.33	0.00	6.0
1	4.0	13.4	0.0719	5	12	163.1	83.4	3.20	0.00	1.5
1	5.0	13.7	0.0724	6	12	139.0	81.3	2.83	0.00	1.0
1	6.0	13.8	0.0693	7	13	125.1	81.2	2.57	0.14	2.0
1	7.0	14.2	0.0697	8	13	111.6	81.0	2.38	0.13	1.0
1	8.0	14.7	0.0664	9	15	105.9	81.5	2.44	0.11	3.0
1	9.0	15.4	0.0685	10	19	111.9	81.8	2.70	0.10	5.0
1	10.0	15.7	0.0689	11	19	104.1	80.9	2.55	0.09	1.0
1	11.0	17.1	0.0711	12	22	105.7	81.4	2.67	0.08	4.0
1	12.0	19.4	0.0793	13	27	113.8	81.9	2.92	0.08	6.0
1	13.0	19.8	0.0819	14	26	107.5	79.7	2.71	0.14	1.0
1	14.0	19.7	0.0806	15	27	103.4	78.6	2.67	0.13	2.0
1	16.0	20.2	0.0827	17	26	92.7	77.4	2.41	0.12	1.0

CASCADE Event Settings

Event Type: Single Electron

of Sims Per Event: 1

Pause

Include Beam Effects

Write Output Electrons

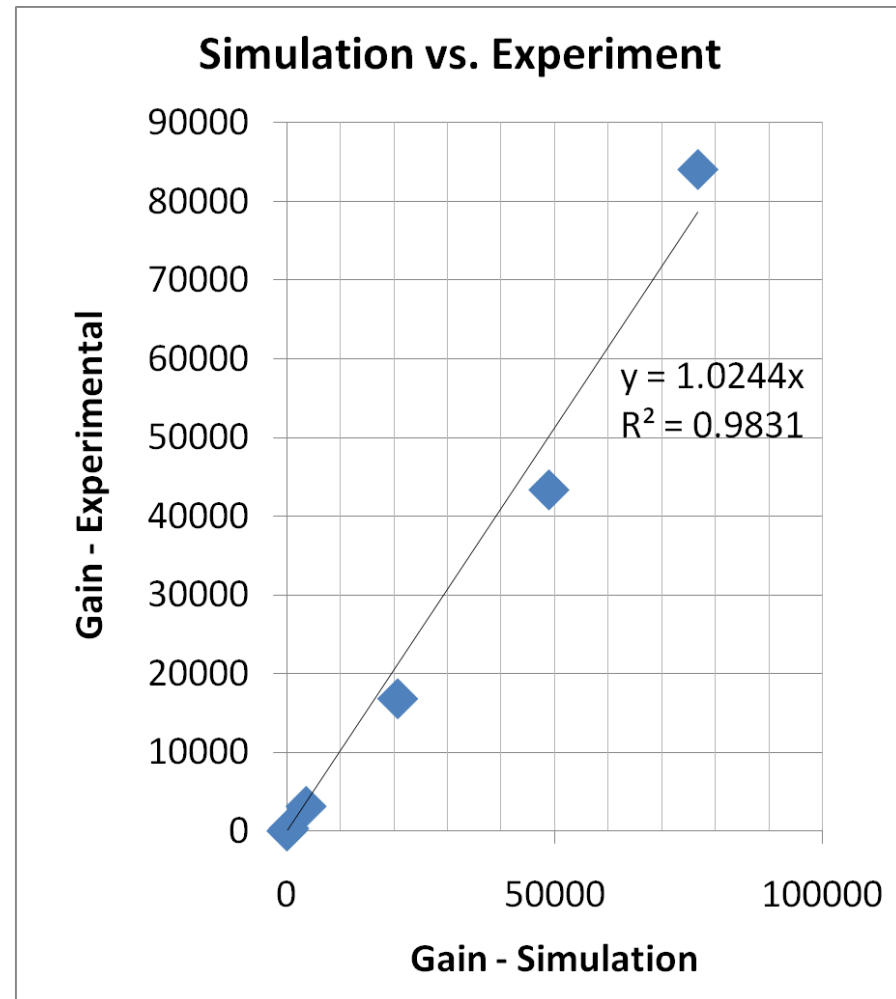
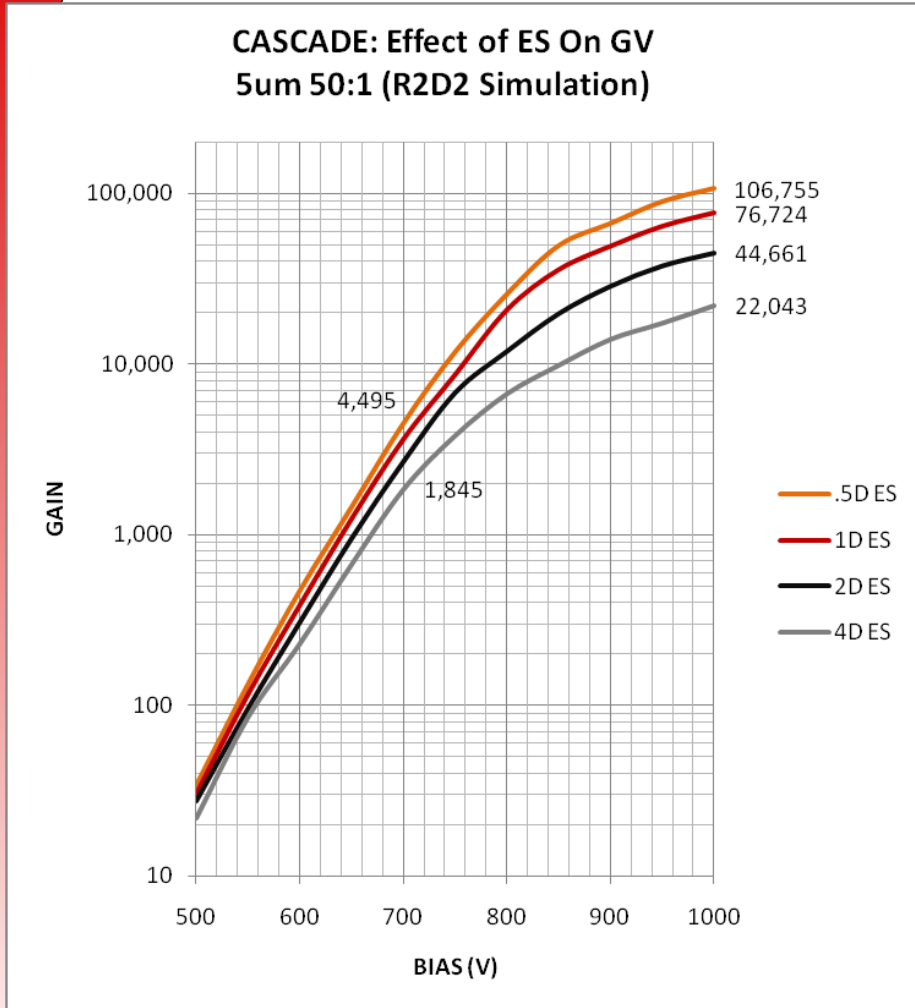
First Strike Efficiency

GV GV1 Single Event

Cancel Fly

Flying.....Complete

MCP CASCADE Experimental Agreement: Gain vs Bias & Endspoiling

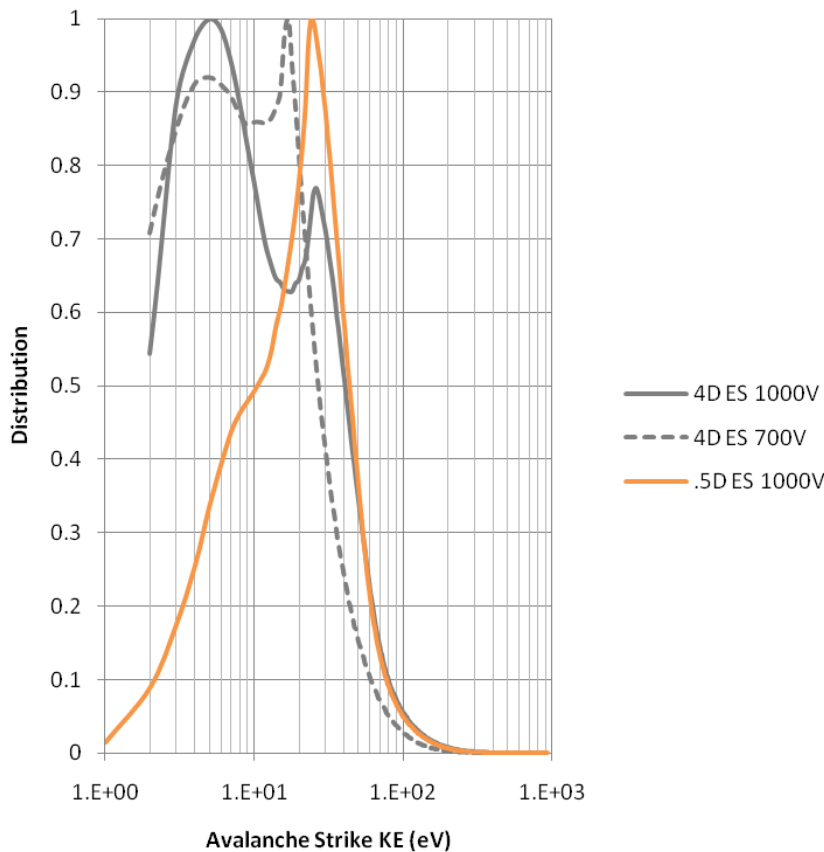




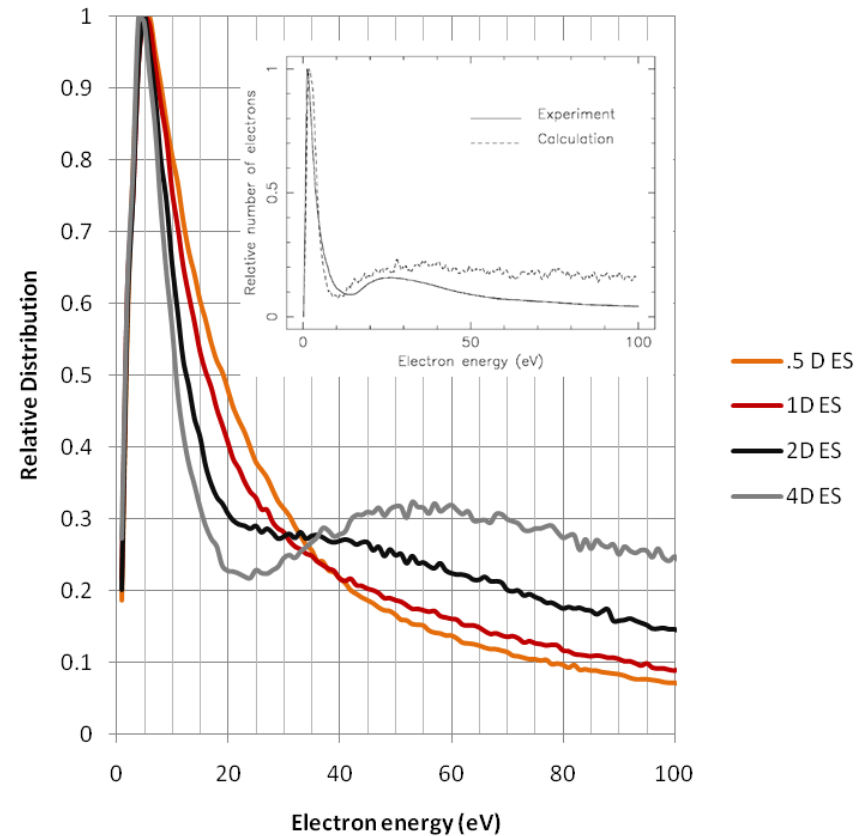
MCP Cascade: Effect of Bias and Endspoiling

inset, from G.J. Price, G.W. Fraser / Nuclear Instruments and Methods in Physics Research A 474 (2001) 188–196

CASCADE Bias Effect On Wall Strike KE Sum 50:1 4D ES (R2D2 Simulation)

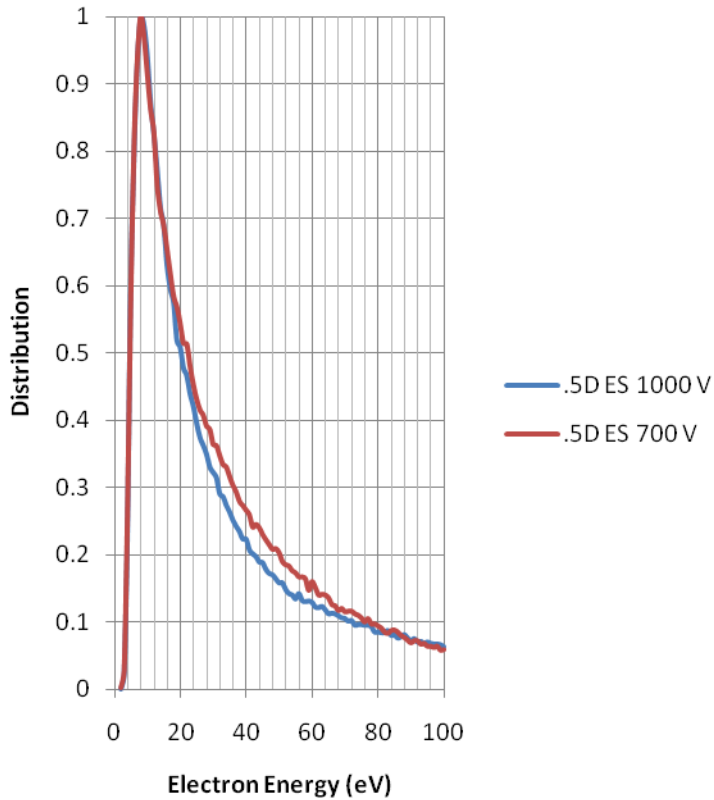


CASCADE: Effect of ES On KE Sum 50:1 At 1000V (R2D2 Simulation)

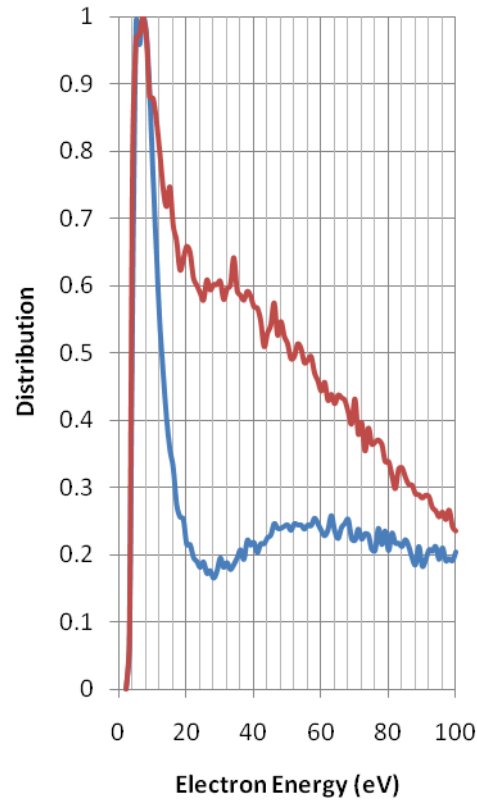


CASCADE: Prediction of Bias & Endspoiling

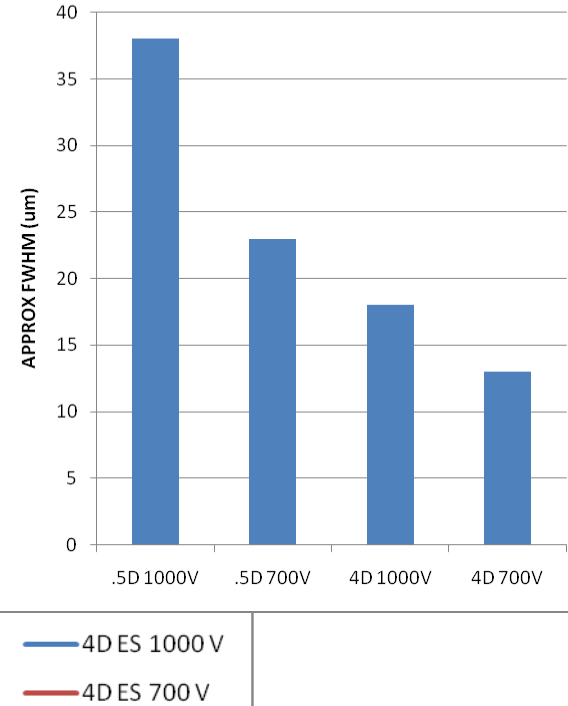
CASCADE: Bias vs. Output Energy 5um 50:1 .5D ES



CASCADE: Bias vs. Output Energy 5um 50:1 4D ES



CASCADE: Event Anode FWHM As a function of ES and Bias 5um 50:1, 4kV/mm at 250um Anode

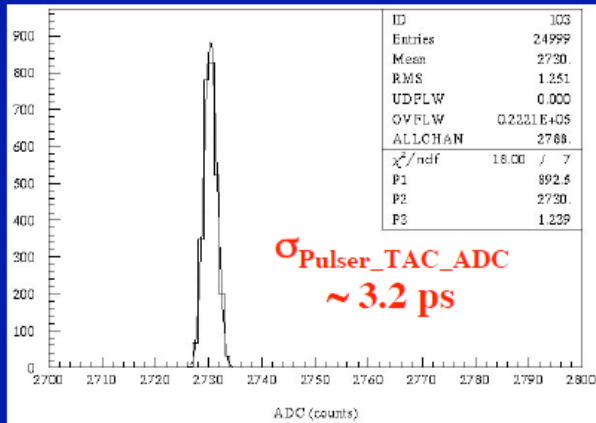


We can we get to...?

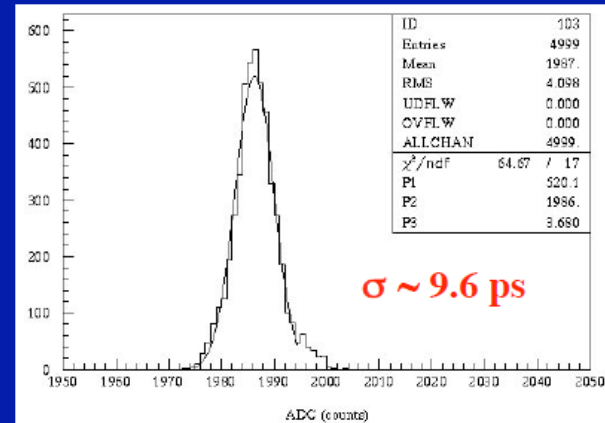
Determine upper limit on $\sigma_{\text{MCP-PMT}}$

- MCP-PMT with 10 μm holes, 64 pads, ground all pads except one being used
- 2.33 kV with Ortec 9327 Amp/CFD (max. allowed voltage is 2.8kV => plenty of margin available for a future magnetic field operation.

Calibrate $\sigma_{\text{Pulser} + \text{TAC_ADC}}$:



Determine σ for $N_{pe} \sim 300$:



(Note: $\sigma \sim 8.6 \text{ ps}$ with Phillips CFD 715)

Upper limit on MCP-PMT contribution to the resolution:

$$\sigma_{\text{MCP-PMT}} < \sqrt{\sigma^2 - \sigma_{\text{PiLas}}^2 (N_{pe}) - \sigma_{\text{Amp_CFD}}^2 - [\sigma_{\text{Pulser+TAC_ADC}}^2 - \sigma_{\text{Pulser}}^2]} < 6.5 \text{ ps}$$

9.6 ps

< 1 ps (PiLas & measure)

6-7 ps (Ortec)

3.2 ps

< 2 ps (manufacturer)

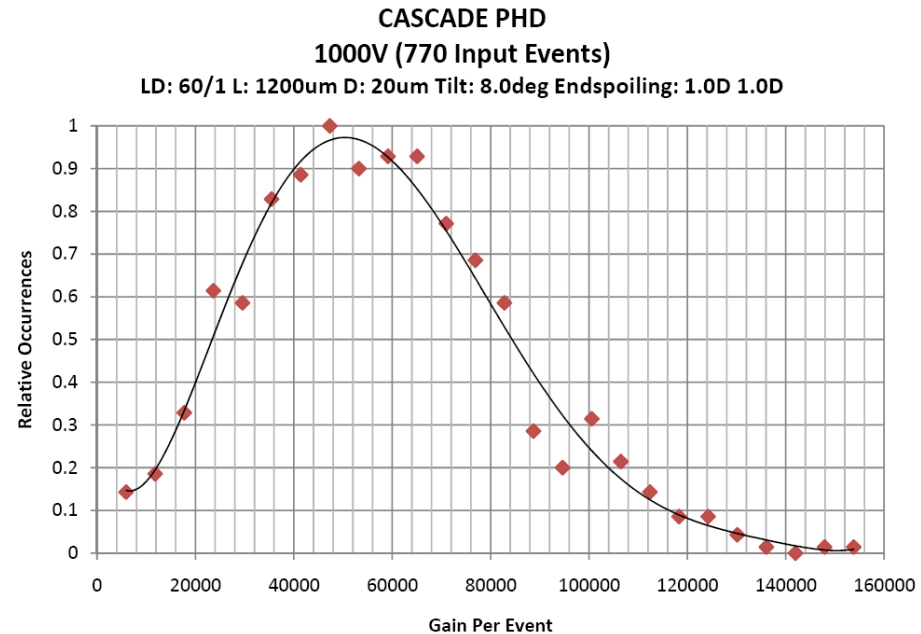
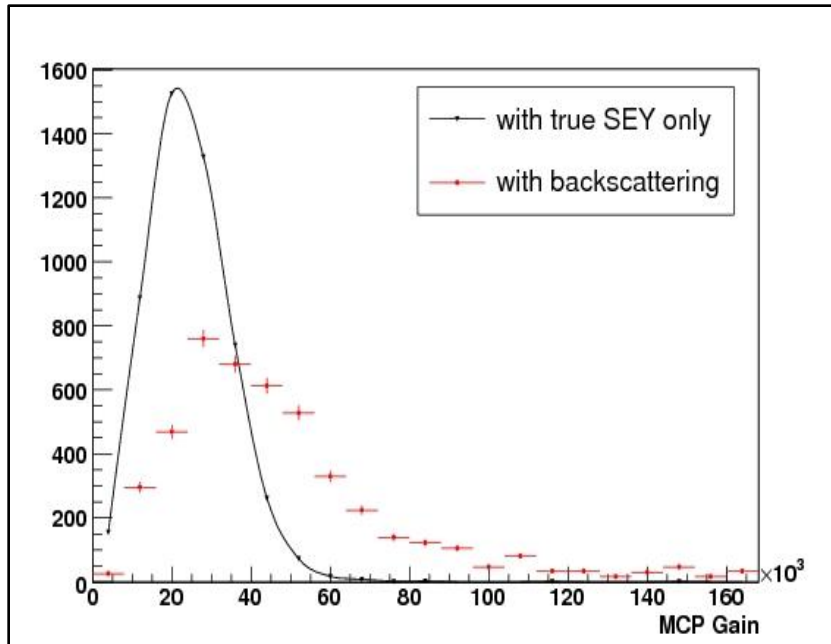
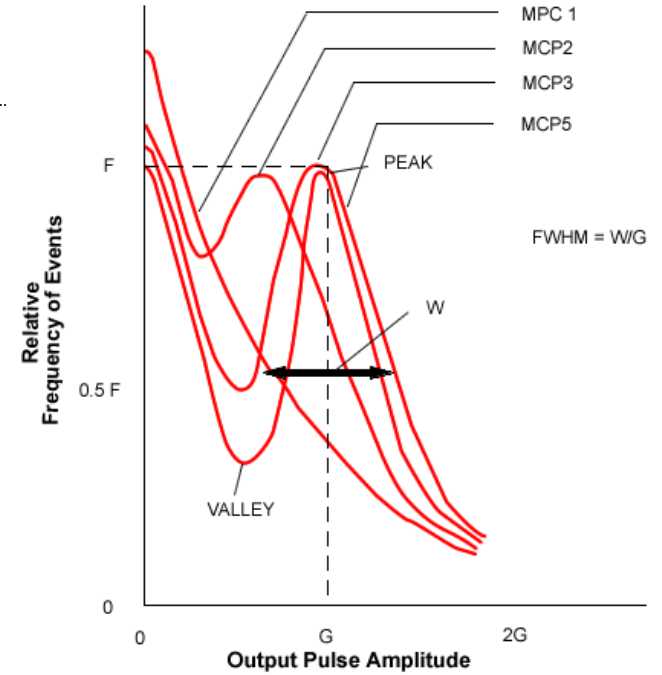
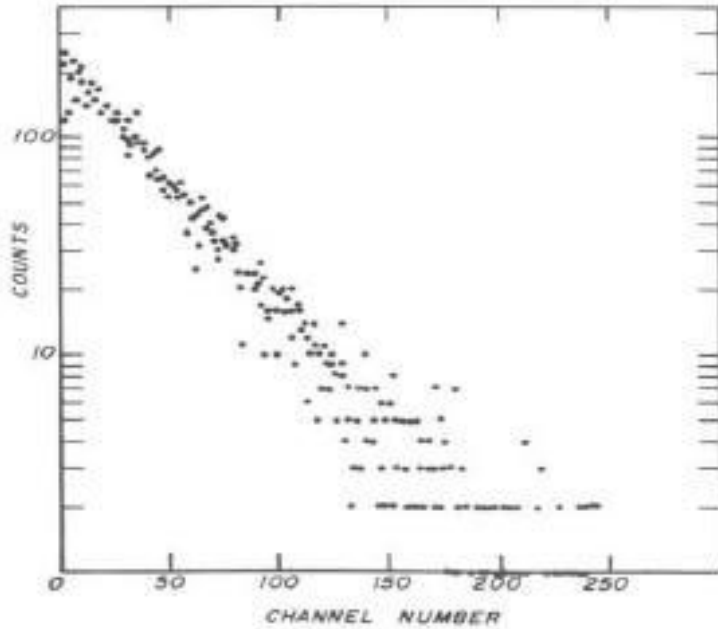
2/25/07

J. Va'vra, MCP-PMT Detectors,
Photonis, Brive, France

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J. WIZA, "MICROCHANNEL PLATE DETECTORS," Nuclear Instruments and Methods, Vol. 162, 1979, p 587

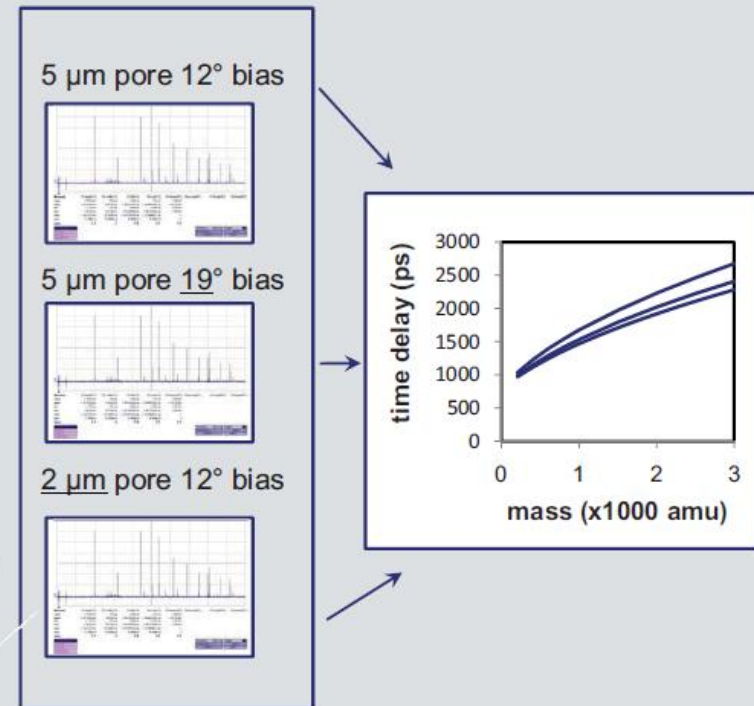
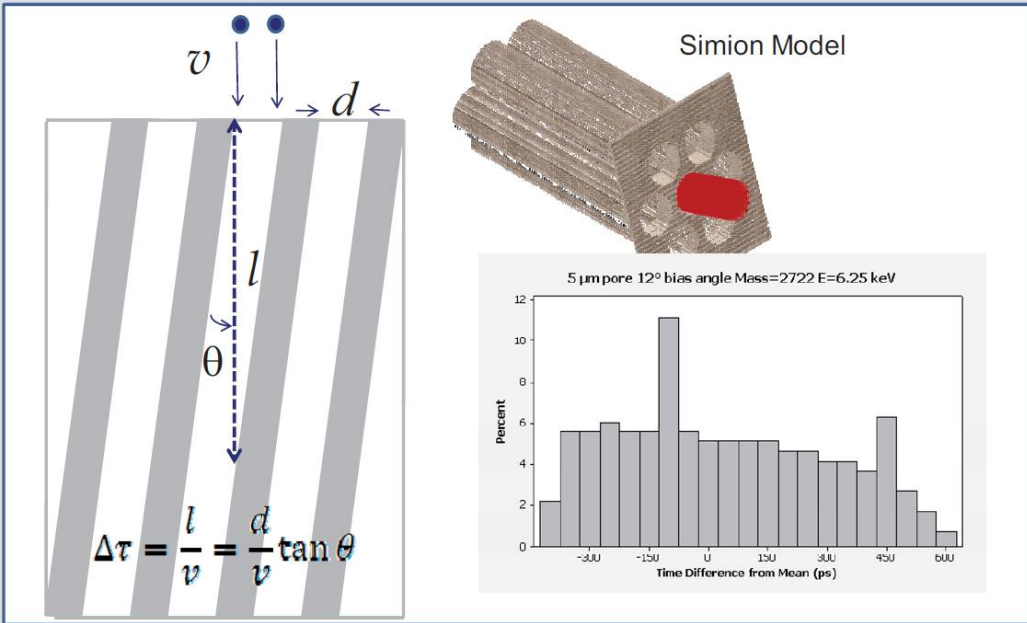
PHD



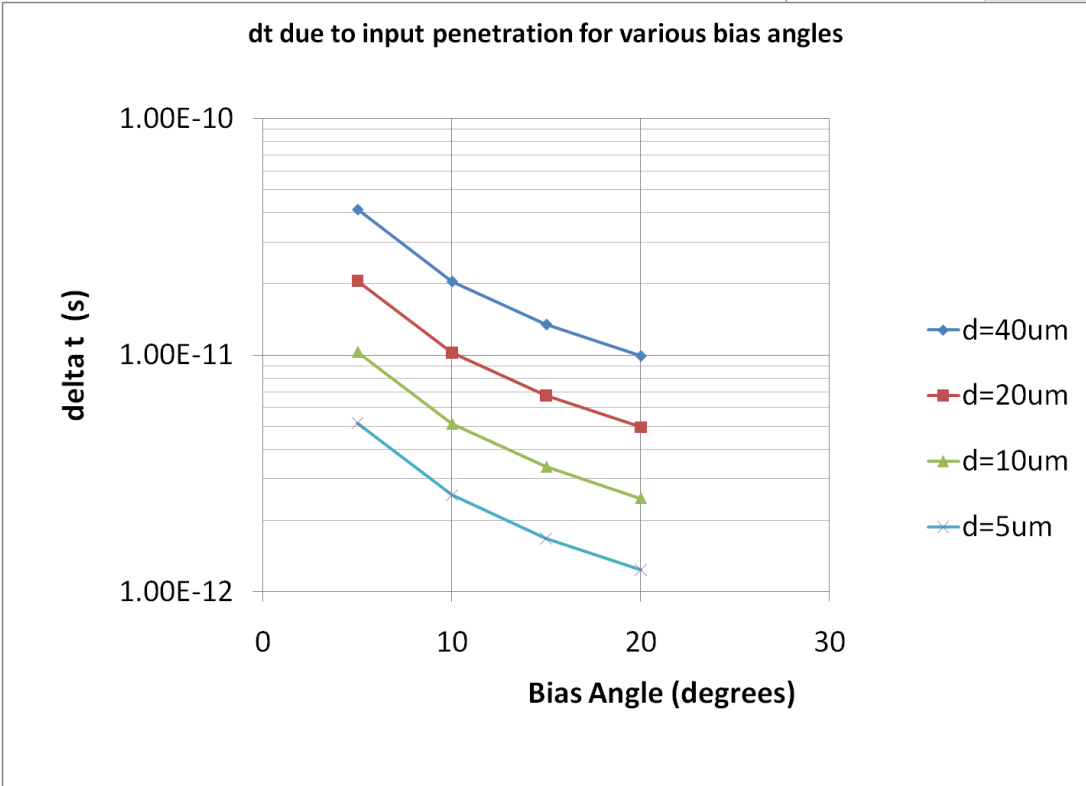
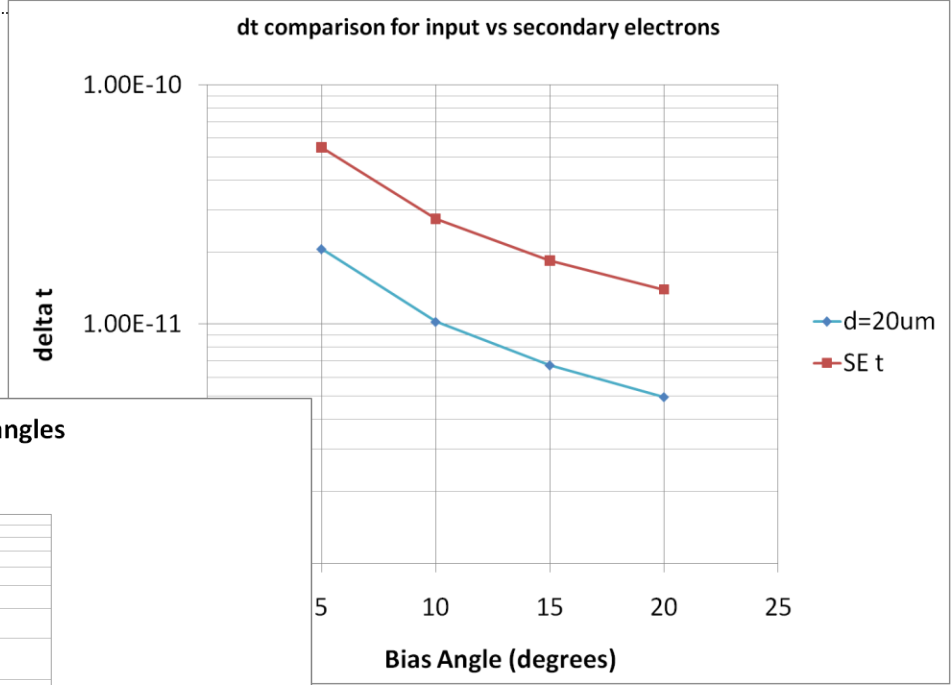
Analogue: Bias and timing for Mass Spec

PHOTONIS

Time Spread due to Ion Arrivals

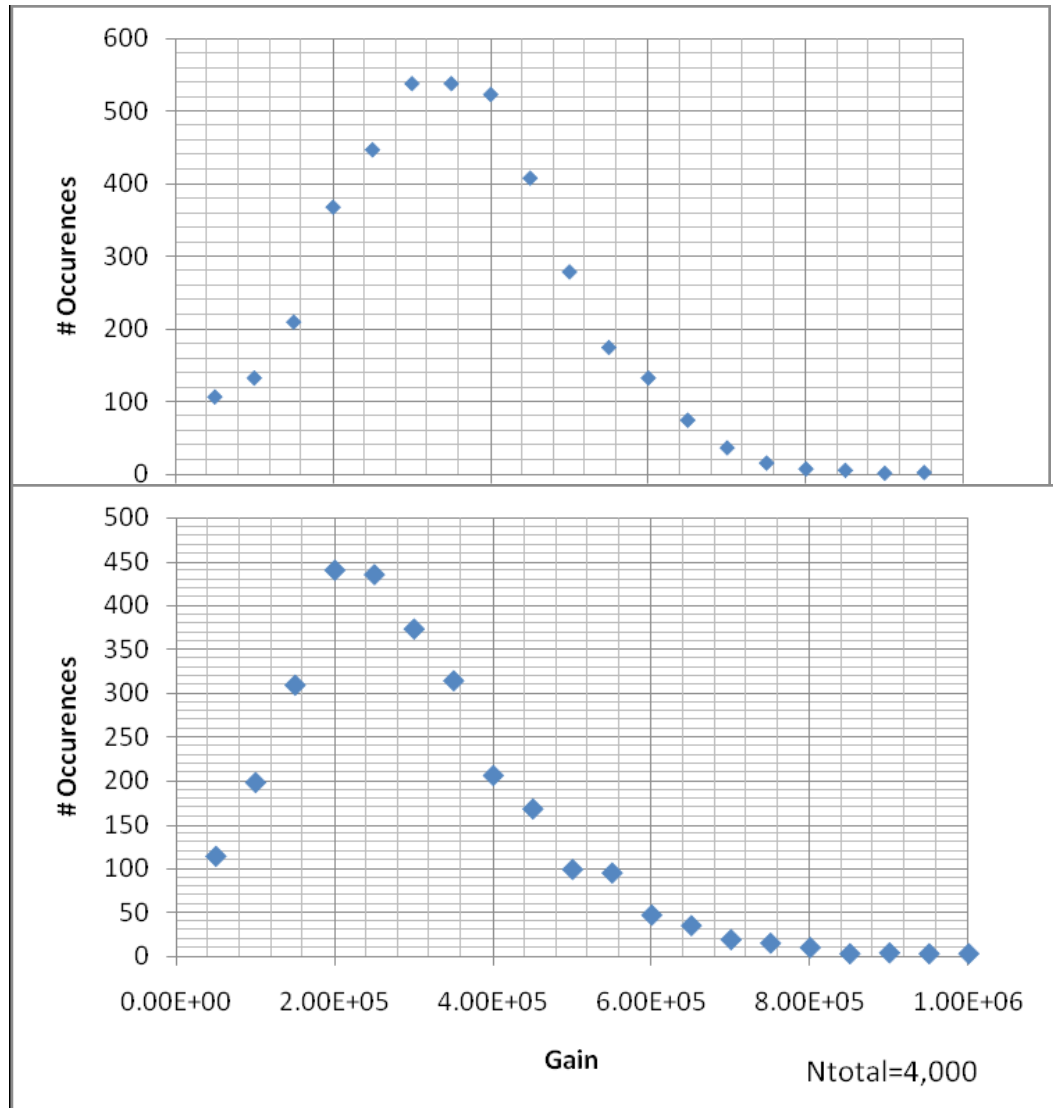


Sub 10ps – Everything Matters



PHD Negative Exponential: first strike?

◀ 1st Strike Fixed position



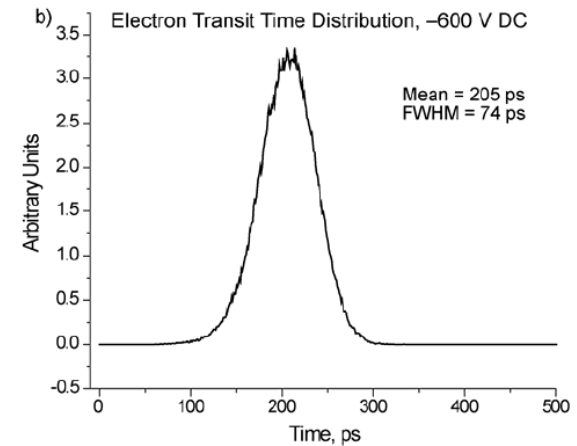
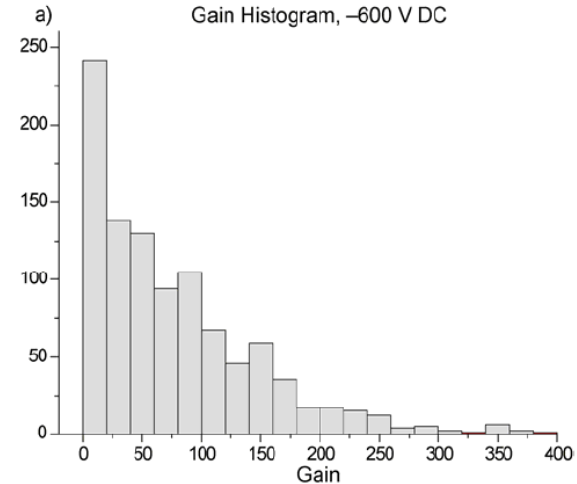
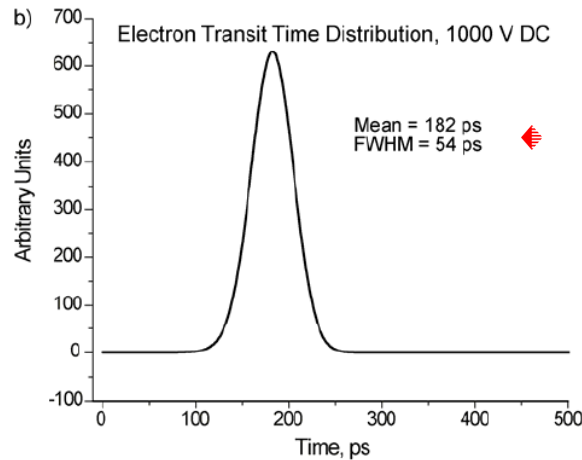
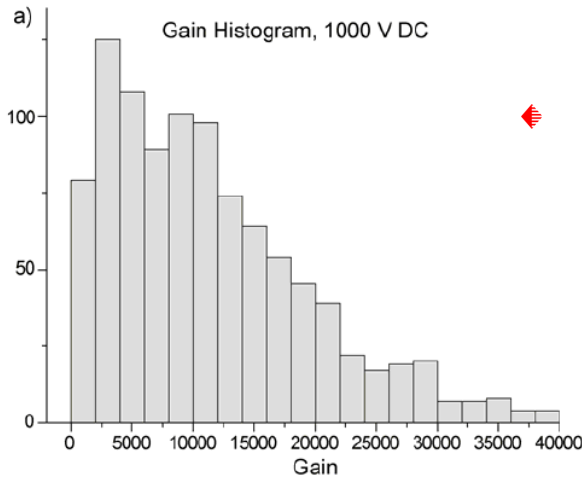
◀ 1st Strike Random position

What happens when MCP Bias is reduced?

"Monte Carlo simulations of microchannel plate detectors I: steady-state voltage bias results," M. Wu, C. Kruschwitz, D. Morgan, J. Morgan; National Security Technologies, 87544 DOE/NV/25946--400

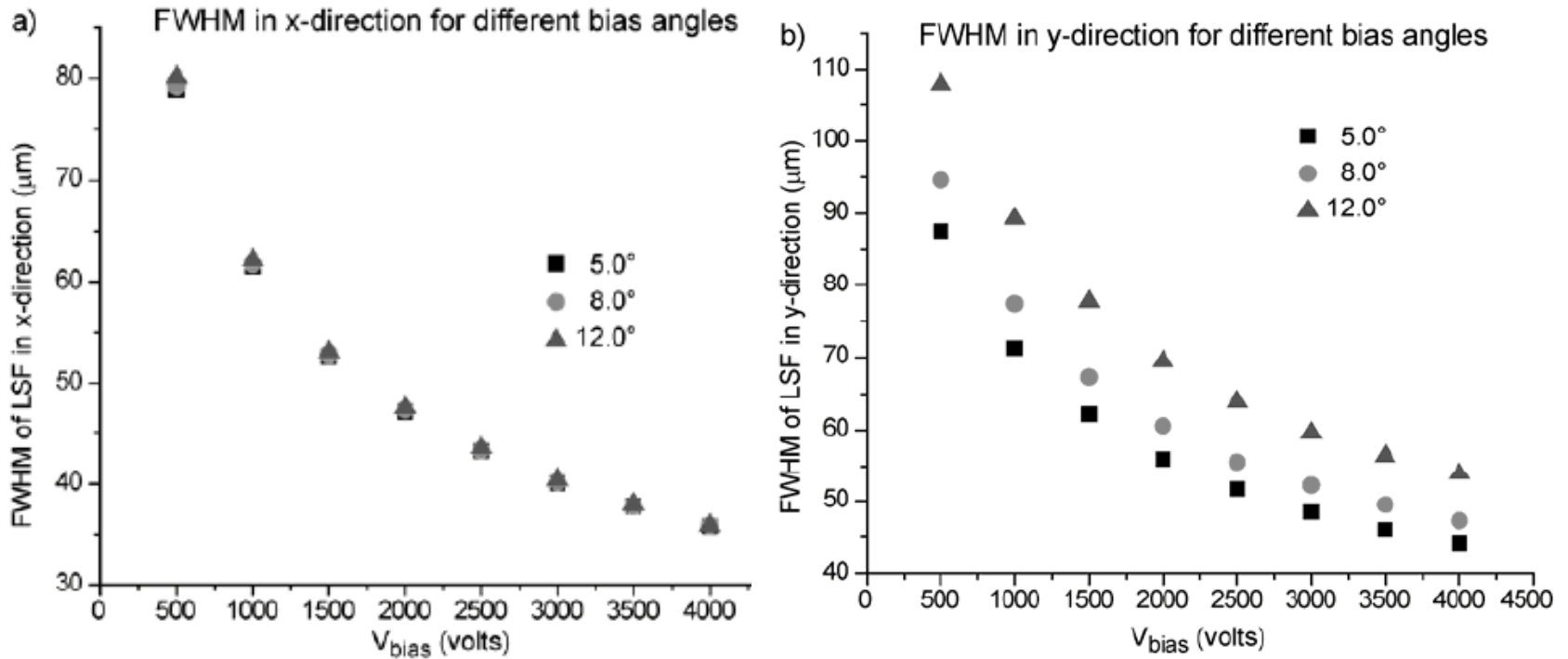
- Lower gain due to smaller electron impact energies reducing SEY.
- Mean transit time is 23ps longer at 600 V due to decreased acceleration and increased number of electron cascades. The electrons travel a shorter distance down the channel between collisions, and thus require more time to reach the output end.

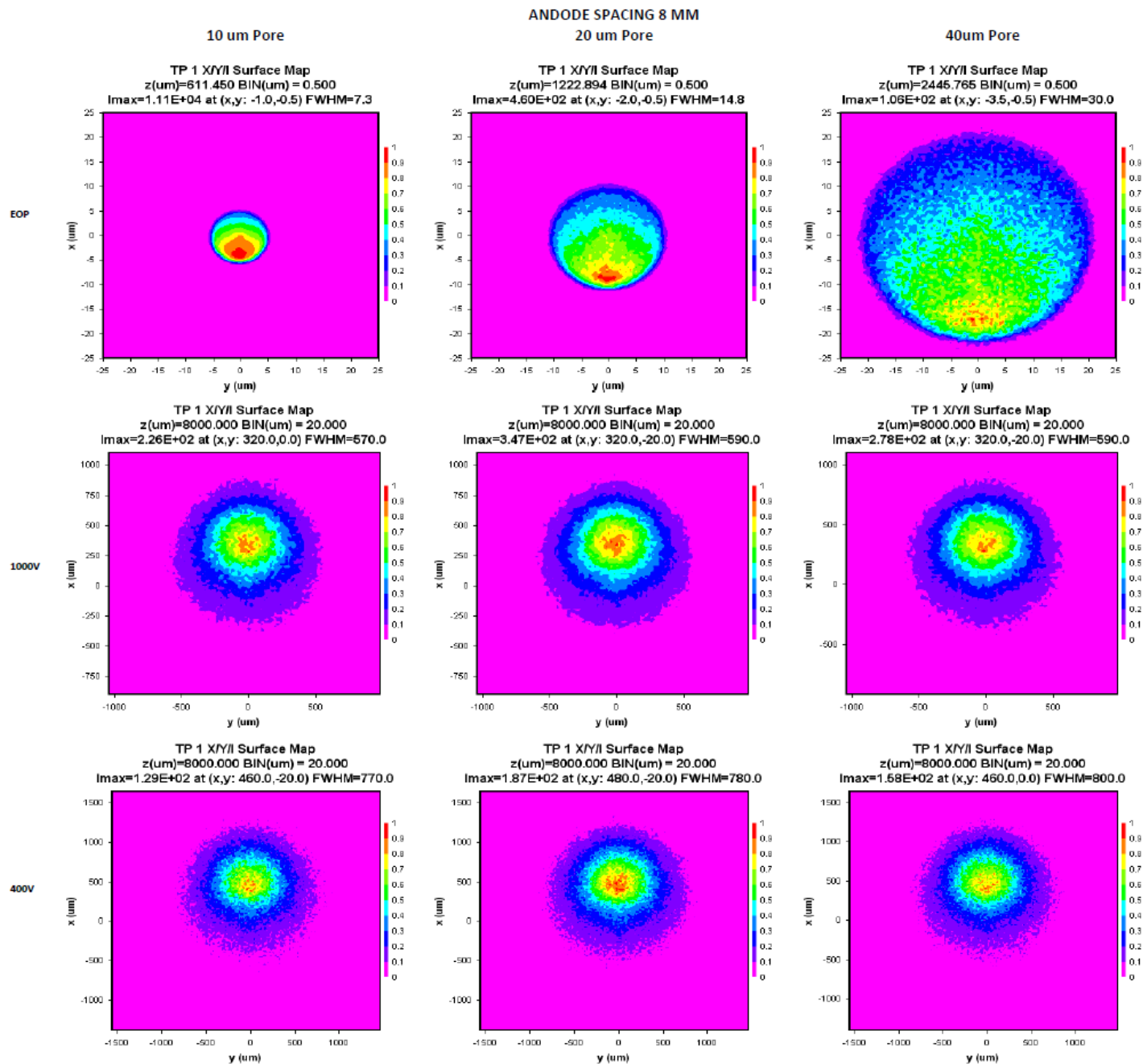
TTS for the 600 V case is 20ps larger, since the spread in SE energy and direction play a greater role at lower bias voltages: electrons travel shorter distances between collisions & impact with lower energy.



Bias angle vs. resolution

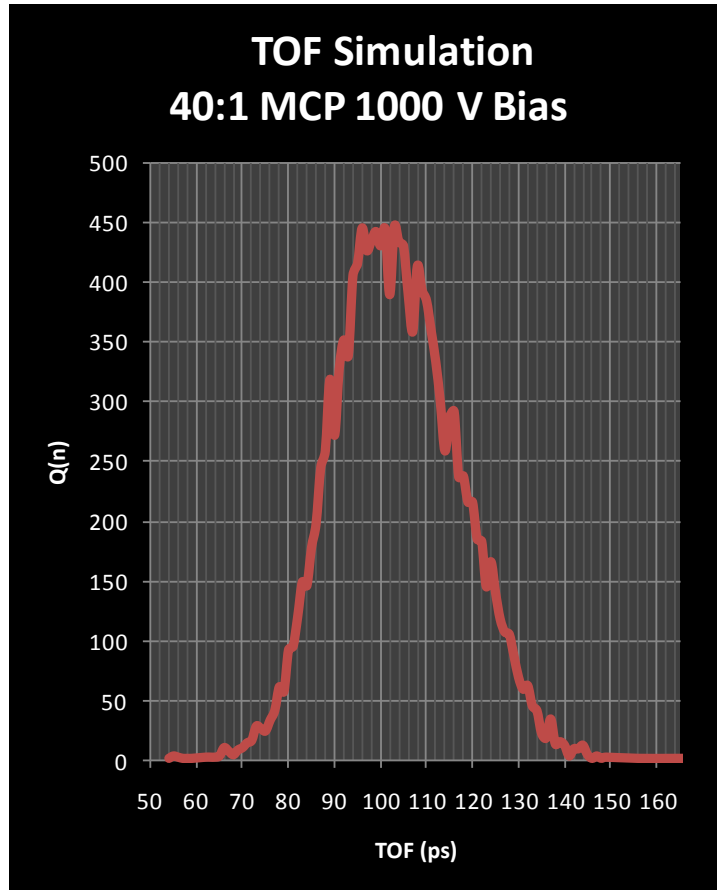
"Monte Carlo simulations of microchannel plate detectors I: steady-state voltage bias results," M. Wu, C. Kruschwitz, D. Morgan, J. Morgan; National Security Technologies, 87544 DOE/NV/25946--400



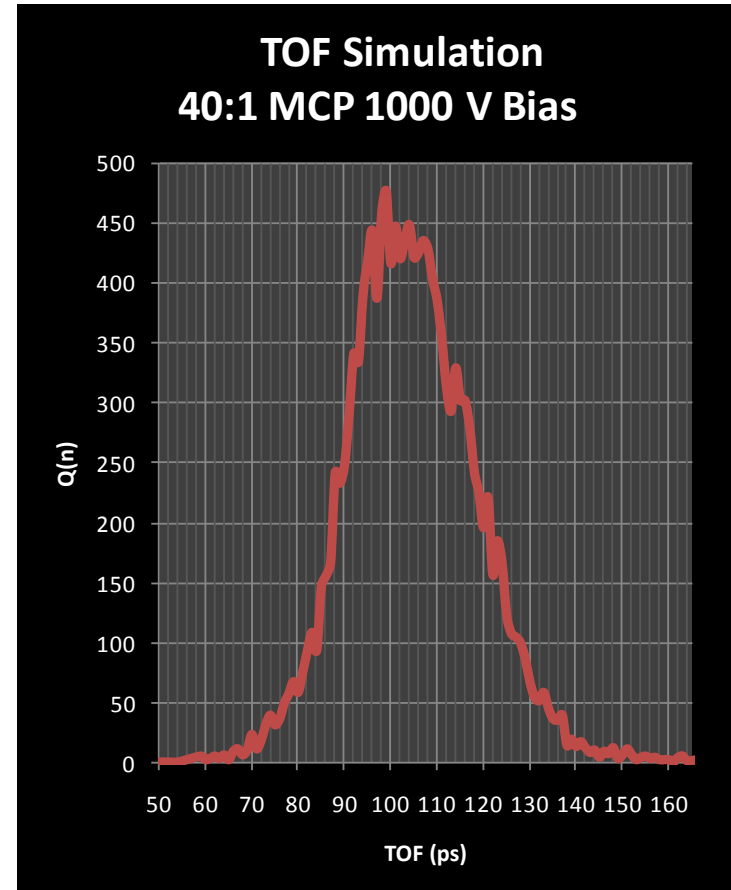


MCP CASCADE TOF Comparison – Pore Exit

Low Yield ES



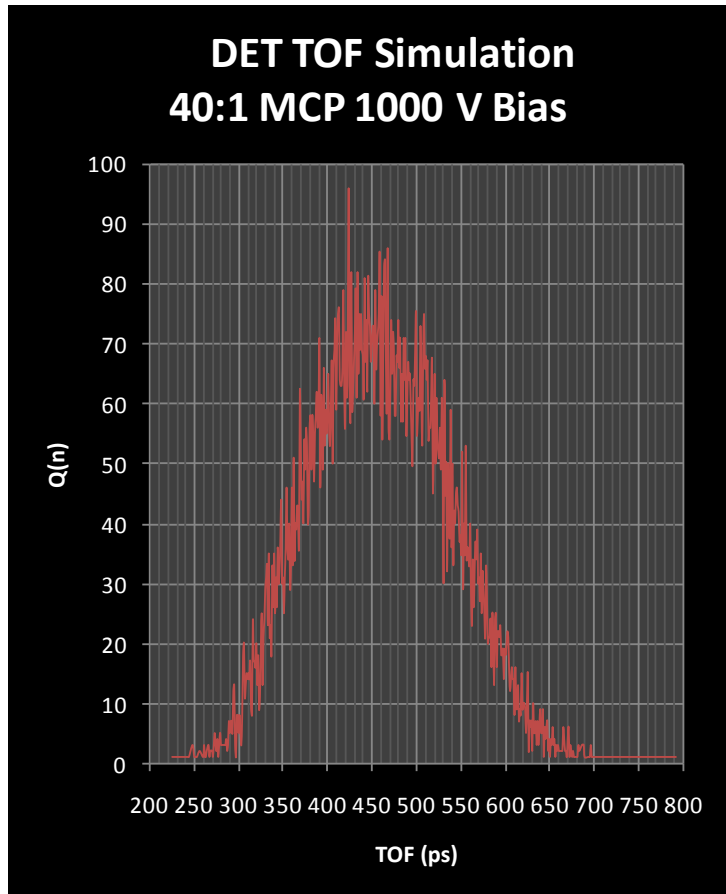
High Yield ES



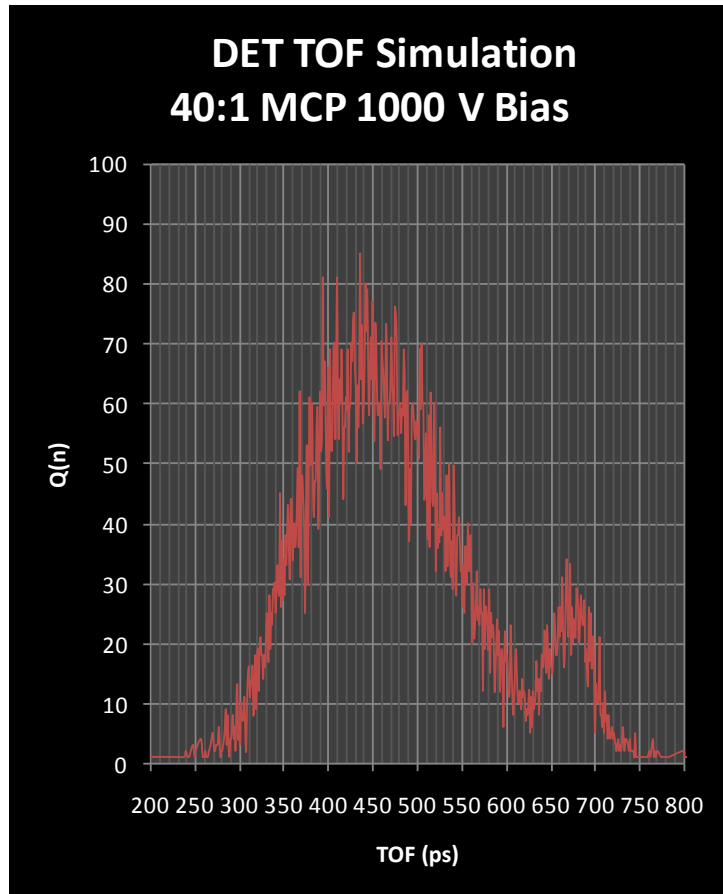
At the EOF the SE yield of the ES material has little influence on TOF

MCP CASCADE TOF Comparison – Detector

Low Yield ES



High Yield ES

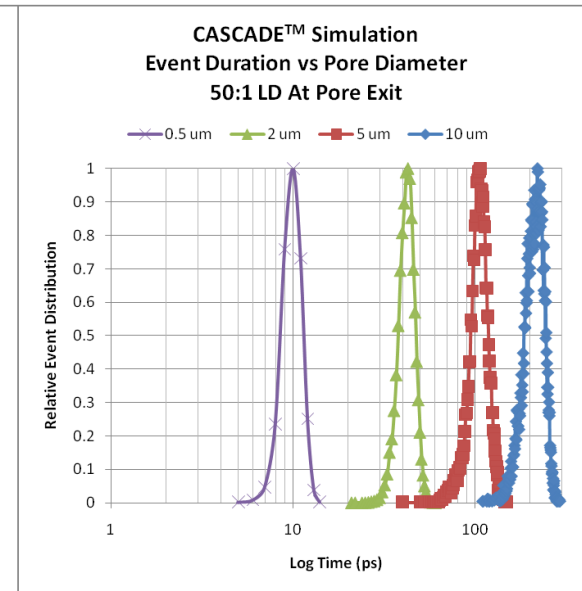
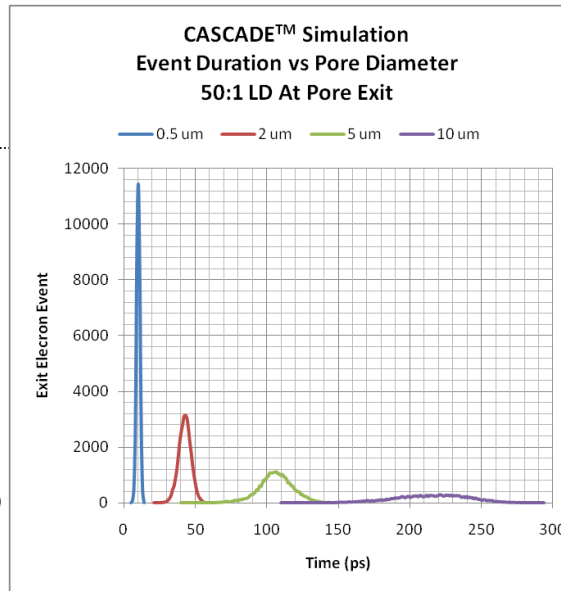


At the Detector the SE yield of the ES material has a significant influence on TOF. The increased low eV electrons will extend the TOF distribution to the detector. In this extreme example, a second peak can be observed for the high yield material.

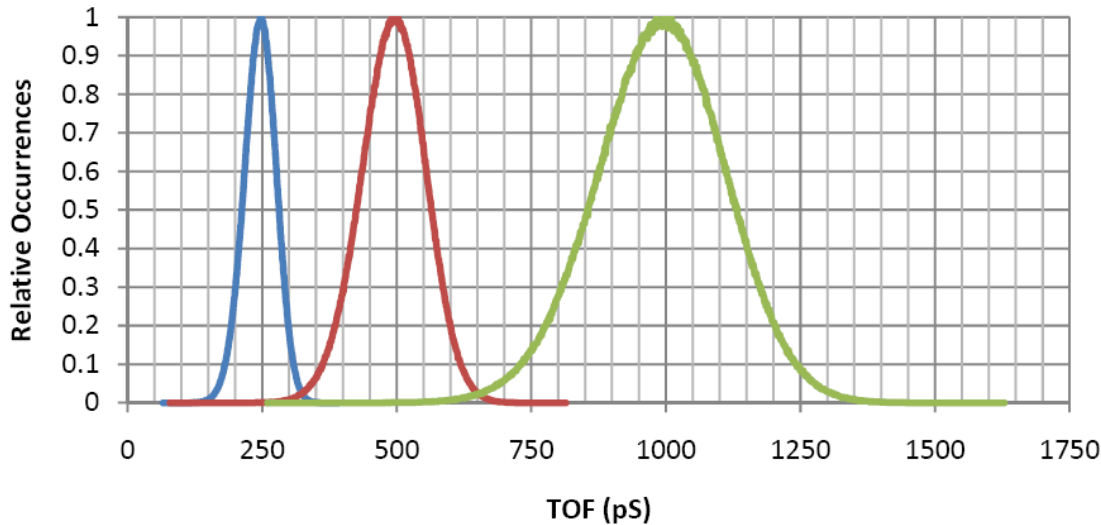


MCP CASCADE: MTT & TTS

CASCADE TOF
Event Start to EOP
1000V



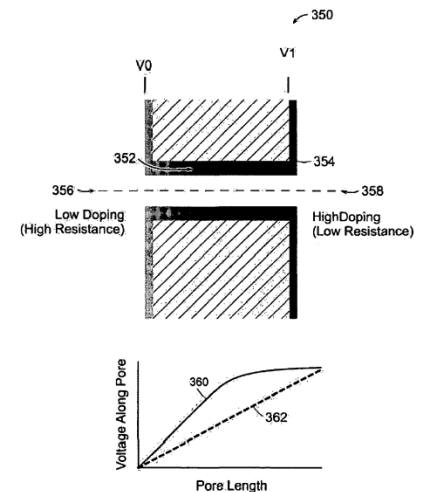
- LD: 60/1 L: 600um D: 10um Tilt: 8.0deg Endspoiling: 1.0D 1.0D
- LD: 60/1 L: 1200um D: 20um Tilt: 8.0deg Endspoiling: 1.0D 1.0D
- LD: 60/1 L: 2400um D: 40um Tilt: 8.0deg Endspoiling: 1.0D 1.0D



Why TTS a consistent fraction of MTT?

TTS Questions – Film properties

- What is the impact of SEY on TTS (effect of gain)
 - more is better?
 - Is there an optimum?
 - Does first strike (high or low) make a difference?
- Does bandwidth (e.g. resistance) make a difference?
- What happens if you tailor the pore nanofilm properties
 - **USP 7408142**





TTS Questions – MCP Geometry

- ◀ What is the optimal pore size, OAR, input funneling, L:D, bias angle for all of the other tradeoffs: gain, spatial resolution, timing resolution
- ◀ What is the role of endspoiling?
- ◀ What is the role of Substrate non-flatness?
- ◀ Can such a fully optimized substrate be made more than once?
- ◀ What does saturation do to TTS?
- ◀ What does gain do to TTS?



TTS Questions – MCP-PMT device

- ◀ What is the optimal interplate gap?
- ◀ What is the optimal bias angle for plate 1? Plate 2?
- ◀ What is the optimal pore size for plate 1? Plate 2?
- ◀ Is there advantage to a single, very high gain MCP? How does this optimization compare to the MCP geometry optimization?